

# **Design, fabrication, and performance testing of a Vacuum Chamber for Pulse Compressor of a 150 TW Ti:sapphire laser**

**P.K.Tripathi<sup>1,\*</sup>, Rajvir Singh<sup>2</sup>, V.K.Bhatnagar<sup>2</sup>, S.D.Sharma<sup>2</sup>,  
SanjaySharma<sup>2</sup>, B. Sisodia<sup>2</sup>, K.Yedle<sup>2</sup>, R.P.Kushwaha<sup>1</sup>, S.Sebastin<sup>1</sup>,  
and G.Mundra<sup>2</sup>**

**Laser Plasma Division<sup>1</sup> & ACDF Section<sup>2</sup>,  
Raja Ramanna Centre for Advanced Technology, Indore**

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# Introduction

- **Purpose of the vacuum chamber** - To house the optical pulse compressor of a **150 TW Ti:sapphire laser system**.
- In pulse compression, the intensity of the laser pulse becomes very high. *When this high intensity laser beam interacts with air medium phase distortion of the laser beam takes place. The phase distortion affects the its focusability.* Hence, the beam after pulse compression has to be transported in high ***vacuum*** to avoid this distortion.
- Standard chamber from OEM was not suitable for our application & it was developed as per our requirement.

# Introduction

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- **Vacuum Chamber** - Cuboidal shape with rectangular & circular demountable ports for entry and exit of the laser beam, vacuum pumping, system cables, and ports to access optics mounted inside the chamber.
- **Size of the chamber** –  
1420mmL x 1200mmW x 820mmH.
- **Vacuum Requirements** - A clean vacuum better than  $5 \times 10^{-5}$  mbar is required for this purpose.

# Features

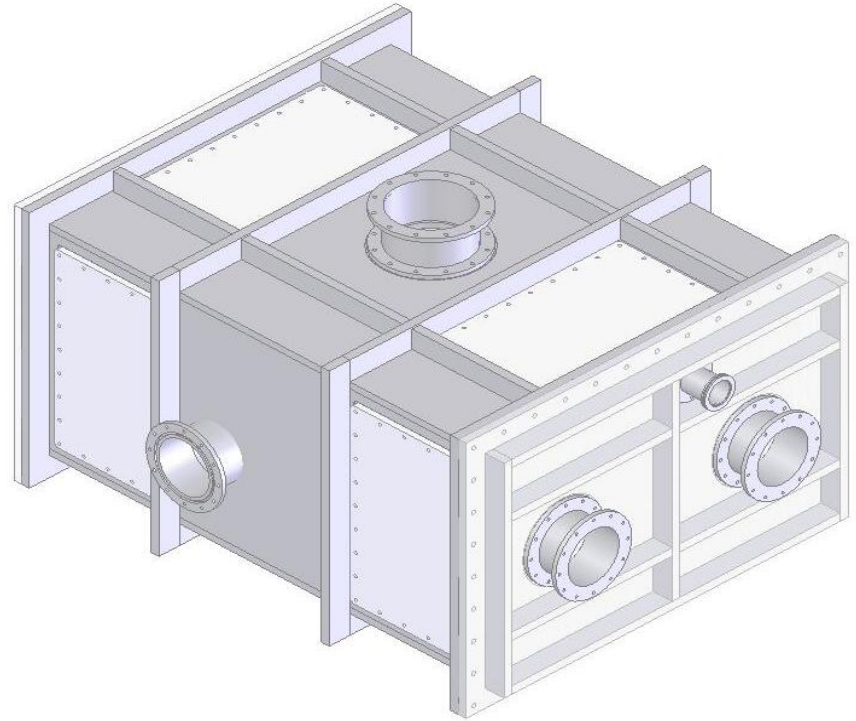
- A vacuum chamber to house the optical pulse compressor of a 150 TW Ti:sapphire laser system.
- Shape - Cuboidal as max. space available
- Volume - 930 liters approx.
- Space - 1370mm x 1030mm x 650mm (L x W x H).
- Ports - Seven demountable rectangular ports of size 250 mm x 500 mm, Circular Ports of 160mm dia.

# Features

- **Access** - Front and back side, chamber can be opened from the sides (opening: 1030 mm x 650 mm) to insert the breadboard.
- **Beam entry port and beam exit port** each of 160 mm inside diameter at right angle.
- **Two measurement ports** of 160 mm inside diameter in one of the side cover plate.
- **Three ports** with DN 63 ISO-K flanges, which are to be used as feed-through ports for system control cables.

# Mechanical Design

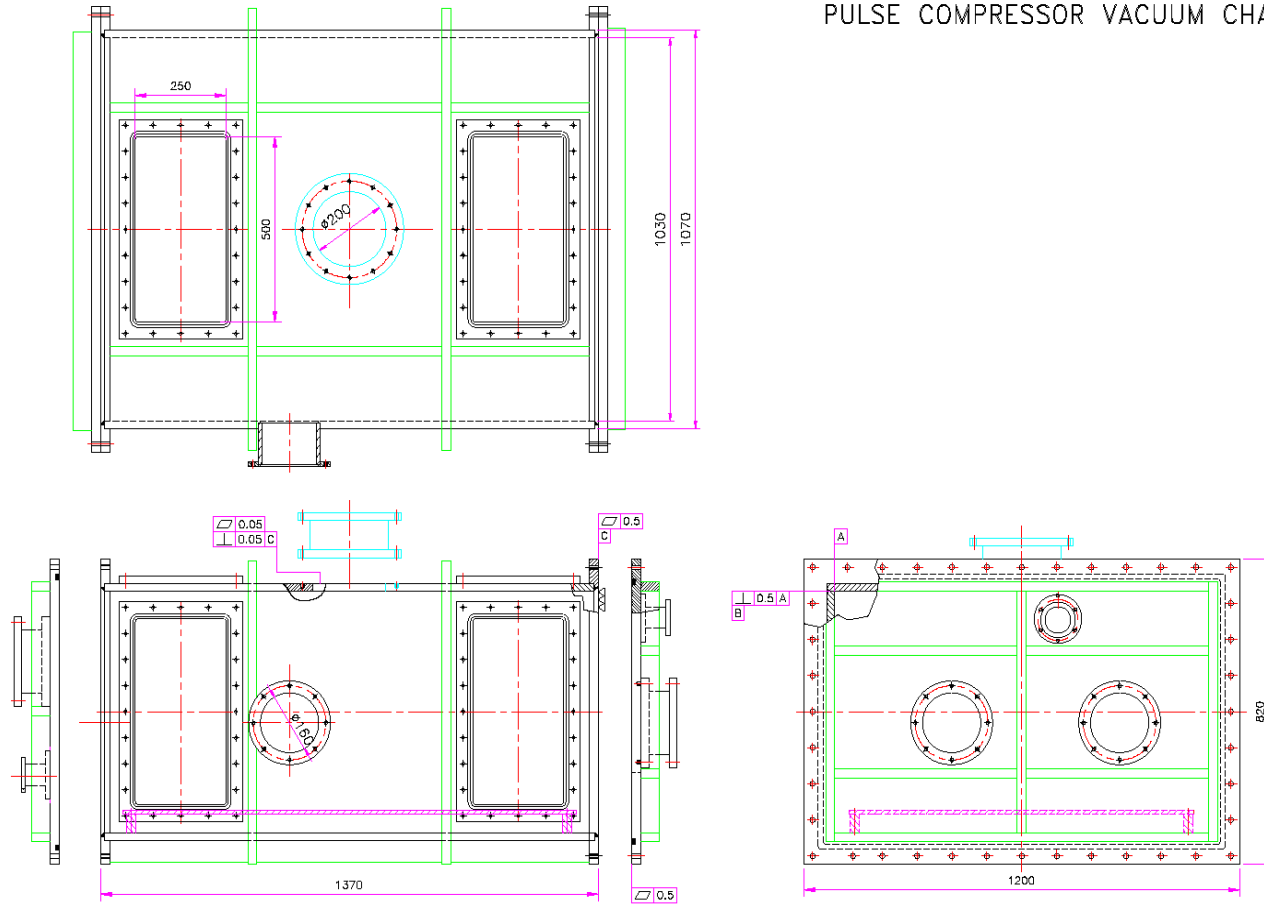
- Chamber design based on theory of plates.
- The chamber is designed rigid enough to withstand the external atmospheric pressure to keep deflection within limit for sealing the demountable joints.



**3-D view of the chamber**

# DESIGN

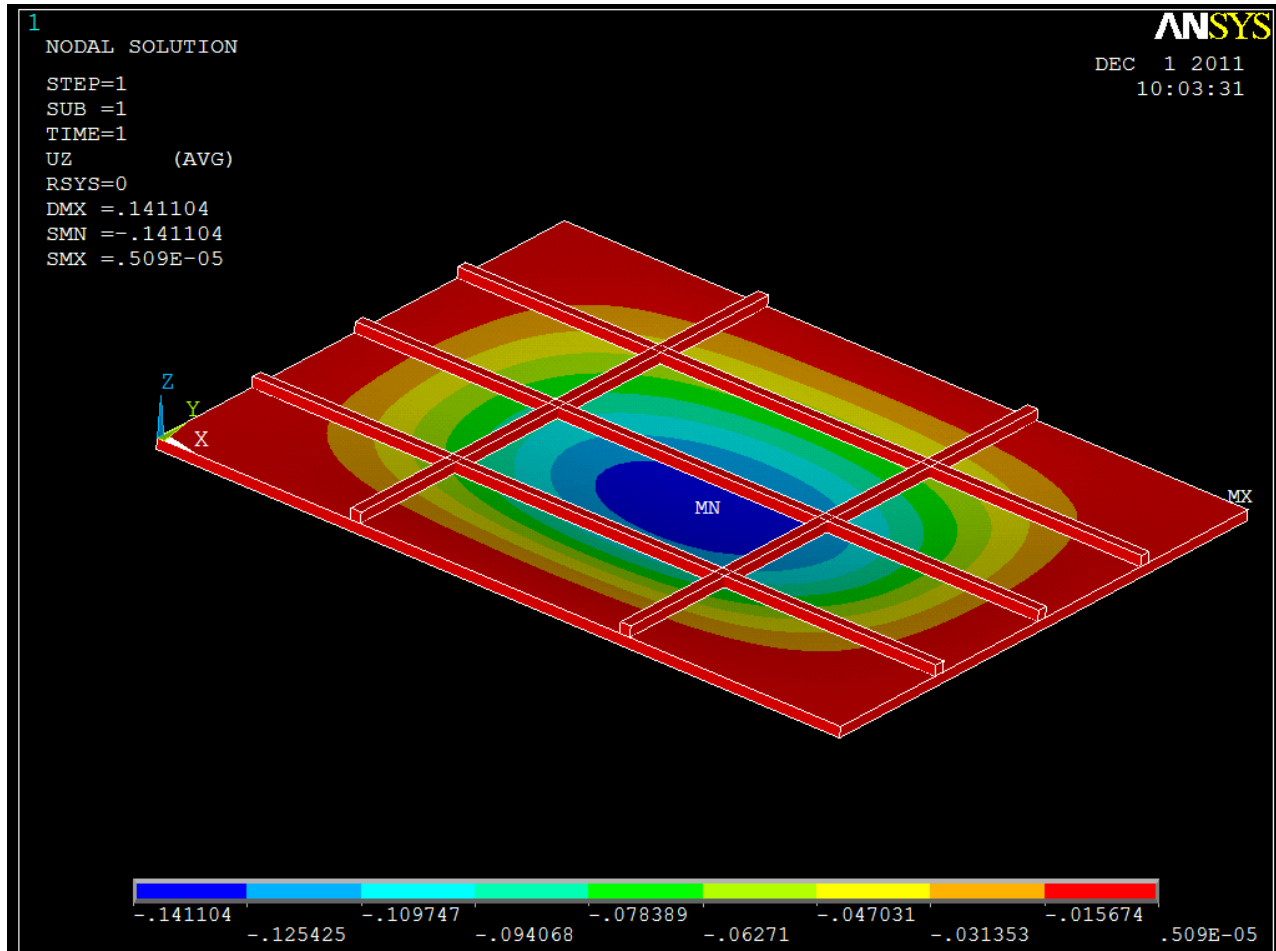
PULSE COMPRESSOR VACUUM CHAMBER





# Mechanical Design

- **Stiffeners** are designed & welded to the walls of the chamber to Reduce and optimize the wall thicknesses & Keep deflections within the desired limit.
- Stiffners Cross Section- 25mmx60mm
- Bottom Plate Thickness- 20mm
- **O'ring grooves** are designed and fabricated to the required precision so that the grooves meet **sealing requirements**.
- **Groove Surface finish** is better than 1.6 microns with no scratch and dents on the sealing surfaces.



## FEM Analysis of Bottom Plate

# Vacuum Design

- **Design of vacuum system** based on **gas load** in the chamber and **vacuum** requirement of the process.
- **Gas load** of the order of  $6 \times 10^{-3}$  mbar-l/s is calculated based on surface area exposed to vacuum and **Specific Out-Gassing Rate (OGR)** of construction materials.
- **An additional gas load** of  $1 \times 10^{-3}$  mbar-l/s is expected due to out gassing of breadboard & its optical arrangement.

# Fabrication

## TIG welding used for fabrication of the chamber -

- In a **Clean Room** under **controlled RH** ( $< 40\%$ ),
- **AWS 5.9 ER 316L filler wire/rod** thoroughly cleaned
- **Ultra pure Argon gas** for shielding & purging
- **Proper fixturing** to avoid the *distortion* during welding.



*Chamber during welding Stage*

# Welding Details

Typical **welding parameters** used are -

- Welding current : 120-150 Amps,
- Filler wire : ER 316L (dia. 2.5 mm and 3.15 mm.)
- Shielding gas : 99.999% pure Argon
- Shielding gas flow rate : 8 Ltrs./min.
- Relative humidity : 35-40% @ 22 to 25°C

# Fabrication

- The chamber was machined on CNC Horizontal boring machine for achieving the desired tolerances.
- Surface finish of the order of 1.6 microns was achieved on sealing surfaces of the components using pocket milling cycle on CNC machine.
- Surface finish of all the 'O' ring grooves is better than 1.6 microns with **no scratches and dents**.



**Chamber machining at CNC Horizontal Boring Machine**





**Photograph of setup during measurement  
of deflection**



# Fabrication

## Chemical Cleaning

- **Main chamber** and other stainless steel parts chemically cleaned and electro-polished to reduce the out-gassing load from them, while all aluminum cover plates are soap cleaned thoroughly to make them vacuum compatible.

# Pumping System

- The pumping system for the above Pulse Compressor Vacuum chamber consists of a TMP with a pumping speed of 1250 l/s. The above TMP was provided with a dry backing pump of 50 m<sup>3</sup>/hr.



*Photograph of the chamber with Pumping system*

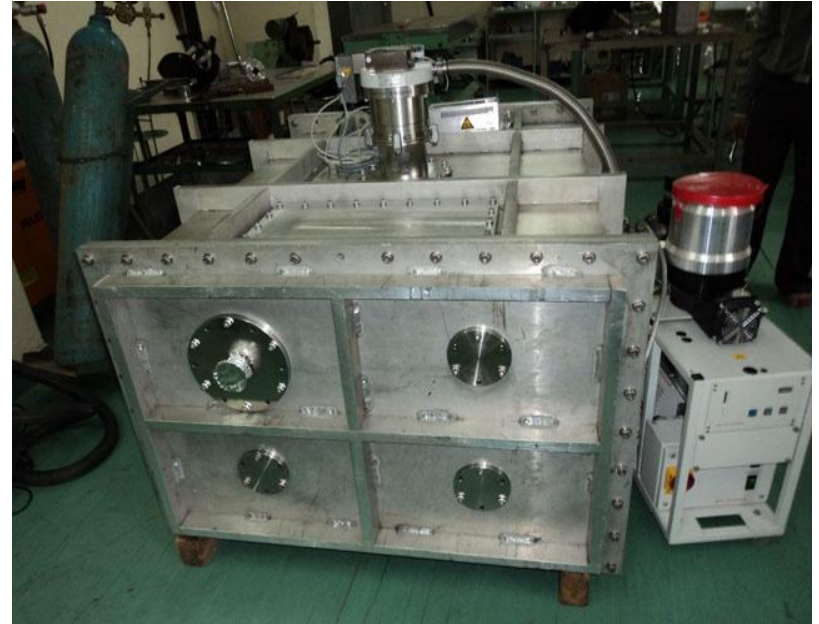
# Pumping System

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- The TMP is mounted in the top of the chamber in the vertical orientation via pneumatically operated gate valve.
- The chamber was rigidly mounted on a Mild Steel stand with levelling provision.

# Vacuum & Leak Testing

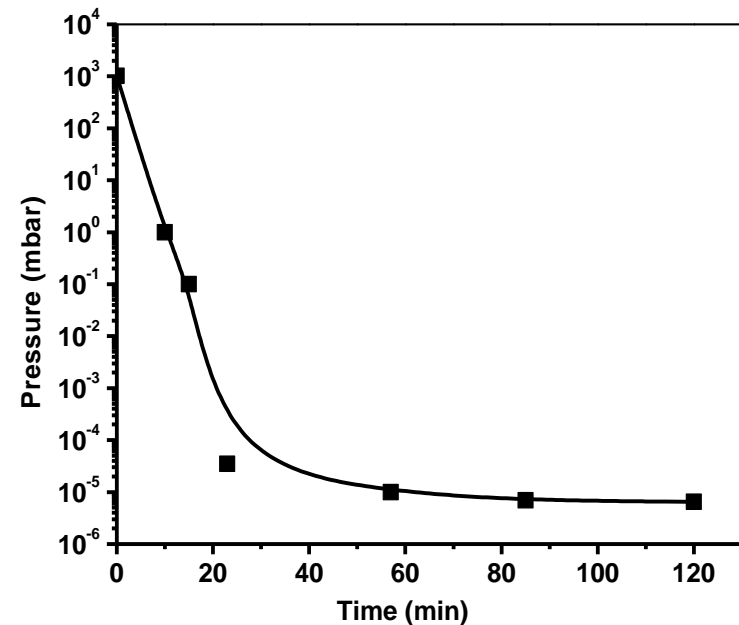
- TMP & Dry Vacuum Pumps used for vacuum pumping.
- Helium MSLD was used for carrying out leak testing.
- A leak tightness of better than  $9 \times 10^{-9}$  mbar-l/s is found for all the joints.



Photograph of leak testing setup

# Vacuum & Leak Testing

- Vacuum achieved -  $10^{-5}$  mbar – 1/2 hour,  $6.5 \times 10^{-6}$  mbar less than two hours using TMP of 1250 lit/sec pumping speed and roughing pump of  $50\text{M}^3/\text{hr}$  pumping speed.



**Pump down curve**

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